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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/942,220	08/29/2001	Michael J. Berman	5201-24700	6921

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EXAMINER

NGUYEN, DANNY

ART UNIT

PAPER NUMBER

2836

DATE MAILED: 01/02/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application N 09/942,220	Applicant(s) BERMAN ET AL. <i>M</i>
	Examiner Danny Nguyen	Art Unit 2836

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
 - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
 - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
 - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).
 - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) Responsive to communication(s) filed on 29 August 2001.

2a) This action is **FINAL**. 2b) This action is non-final.

3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) Claim(s) 1-22 is/are pending in the application.

4a) Of the above claim(s) _____ is/are withdrawn from consideration.

5) Claim(s) _____ is/are allowed.

6) Claim(s) 1-22 is/are rejected.

7) Claim(s) _____ is/are objected to.

8) Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) The specification is objected to by the Examiner.

10) The drawing(s) filed on 29 August 2001 is/are: a) accepted or b) objected to by the Examiner.

Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).

11) The proposed drawing correction filed on _____ is: a) approved b) disapproved by the Examiner.

If approved, corrected drawings are required in reply to this Office action.

12) The oath or declaration is objected to by the Examiner.

Priority under 35 U.S.C. §§ 119 and 120

- 13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).

a) All b) Some * c) None of:

 1. Certified copies of the priority documents have been received.
 2. Certified copies of the priority documents have been received in Application No. _____.
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).

a) The translation of the foreign language provisional application has been received.

15) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- 1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413) Paper No(s). _____
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 5) Notice of Informal Patent Application (PTO-152)
3) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 6) Other: _____

DETAILED ACTION

Specification

1. The disclosure is objected to because of the following informalities: Page 7, line 18, there is a mistyping; "the farther" should be read "the further". Appropriate correction is required.

Drawings

2. Figures 1, 2, and 3 should be designated by a legend such as --Prior Art-- because only that which is old is illustrated. See MPEP § 608.02(g). A proposed drawing correction or corrected drawings are required in reply to the Office action to avoid abandonment of the application. The objection to the drawings will not be held in abeyance.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

3. Claims 1-3, 6-15, 18-22 are rejected under 35 U.S.C. 102(b) as being anticipated by Collins et al. (USPN 5,684,669).

Regarding to claims 1, 3, Collins et al. disclose a system comprises a chuck (122) equipped with a lifting mechanism (136) wherein the chuck is dimensioned to receive the wafer (118) and the lift mechanism is adapted to release the wafer from the chuck; a voltage source (102) operably coupled to the chuck and adapted to impart an electronic charge to the chuck and opposite electronic charge to the wafer, producing an electrostatic attraction between the wafer and the chuck (see col. 7, lines 23-33); a sensor adapted to measure a force due to the electrostatic attraction, wherein the force is in opposition to the lifting mechanism (a force gauge attached to the lifting mechanism, see col. 8, lines 20-23) ; and control system (a computer control system 100 applies a reverse polarity chucking voltage to the wafer and the chuck, see col. 7, lines 21-32) adapted to neutralize the electrostatic attraction between the wafer and the chuck by reversing the polarity of the voltage source reducing the first and the second electronic charge until the force opposing the lifting mechanism reaches a predetermined minimum as indicated by the sensor (also see col. 8, lines 14-54).

Regarding to claim 2, Collins et al. disclose the lifting mechanism comprises at least one extendable lifting pin (134) driven by the solenoid (within the lifting mechanism 136).

Regarding to claims 6, 13,18, Collins et al. disclose the lifting mechanism comprises at least one extendable lifting pin (134) driven by a pneumatic or hydraulic pressure actuated piston (a pneumatic lift mechanism 136).

Regarding to claims 7,14, 19, 20 Collins et al. disclose the sensor comprises a pressure sensor (flow rate monitor within the gas supply device 131) adapted to

measure equivalent to force opposing the lifting mechanism and to forward the measured pressure to the control system (100), (see col. 8, lines 14-39).

Regarding to claim 8, Collins et al. disclose the control system further limits the pressure to the piston until the pressure opposing the extensible lifting pin reaches a minimum, and then to increase the pressure to the piston to enable the lifting mechanism to raise the wafer off the chuck (see col. 8, lines 15-43).

Regarding to claims 9, 10, 21, 22, Collins et al. disclose the sensor (the flow gas monitor within the gas supply device 131) comprises an orifice (134) at an interface between the wafer (118) and the chuck (122) operably coupled to the chuck are a line (an interface line between the computer control system and cooling gas supply) through which pressure may be applied to the wafer through the orifice; and a sensor (a gas flow monitor attached inside the computer control system, see col. 8, lines 25-27) adapted to indicate to the control system the presence or absence of pressure at the orifice.

Regarding to claim 11, Collins et al. disclose a method for releasing a semiconductor wafer (see fig. 1) comprises sensing electrostatic attraction between a wafer and a chuck electrically charged opposite one another (see col. 7, lines 21-34); neutralizing the electrostatic attraction by reversing the charge applied to the wafer and the chuck (see col. 1, lines 18-21); and when the sensed electrostatic attraction achieves a predetermined minimum, lifting the wafer from the chuck (see col. 8, lines 48-51, and see fig. 4, at step 216).

Regarding to claim 12, Collins disclose placing the wafer on the chuck (operated by robot arm, see col. 7, lines 6-7); charging the wafer and the chuck opposite one another (see col. 7, lines 20-28).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

4. Claims 4, 5, 16, 17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Collins et al. Collines et al. in view of Mett et al. (USPN 6,304,424). Collins et al. disclose all limitations of claims 1 and 11 except for having a current monitor as claimed. Met et al. disclose a current monitor circuit (108B, see fig. 1). It would have been obvious to one having skill in the art at the time the invention was made to modify the circuitry of Collins et al. with a current monitor circuit as taught by Mett et al. in order to monitor the chuck leakage current (see Mett et al., col. 8, lines 8-10).

Conclusion

5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Danny Nguyen whose telephone number is (703)-305-5988. The examiner can normally be reached on Mon to Fri 8:00 AM to 4:30 PM.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Brian Sircus can be reached on (703)-308-3119. The fax phone numbers for the organization where this application or proceeding is assigned are (703)-872-9318 for regular communications and (703)-872-9319 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)-308-0956.

DN

DN

December 26, 2002



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